

{STA} {Caplus Japco, Inc., USA/12} {update
(FILE 'HOME' ENTERED AT 14:08:09 ON 11 JUN 2003) G.C.'3}

FILE 'CAPLUS' ENTERED AT 14:08:20 ON 11 JUN 2003

L1 176563 S POLISH? OR CHEMIPOLISH? OR CHEMIMECH? OR PLANARIZ? OR LAP? OR
L2 1791741 S CONTROL?
L3 35286 S ENDPOINT? OR END(W)POINT?
L4 84 S L1 AND L2 AND L3
L5 42 S L4 AND (WAFER? OR SEMICONDUCT? OR CHIP?)
L6 42 S L4 NOT L5
L7 2 S L6 AND (CONTROLER? OR CONTROLLER?)

FILE 'JAPIO' ENTERED AT 14:10:20 ON 11 JUN 2003

L8 59 S L6
L9 20 S L5
L10 7 S L7

FILE 'INSPEC' ENTERED AT 14:11:14 ON 11 JUN 2003

L11 19 S L5
L12 3 S L7

FILE 'USPAT2' ENTERED AT 14:12:20 ON 11 JUN 2003

L13 60 S L1(P)L2(P)L3
L14 13 S L13(P)(CONTROLLER? OR CONTROLER?)
L15 55 S L13 AND (SEMICONDUCT? OR WAFER? OR CHIP?)
SET HIGH ON
L16 55 S L13 AND L15
L17 43 S L16 NOT L14
L18 10 S L13(P)PLATEN?
L19 2 S L17 AND L18
L20 41 S L17 NOT L19
SAVE POLISHL20/A L20